

PATENT APPLICATION NO.: 10/584,301  
ATTORNEY DOCKET: 55320.000402IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Number : 10/584,301 Confirmation No.: 3201  
National Stage of Int'l  
Application No. PCT/DK03/000934  
Applicant : Henrik JENSEN, *et al.*  
Filed : June 23, 2006  
§371 Date : December 23, 2003  
Title : METHOD AND APPARATUS FOR PRODUCTION OF A  
COMPOUND HAVING SUBMICRON PARTICLE SIZE  
AND A COMPOUND PRODUCED BY THE METHOD  
TC/Art Unit : 1615  
Examiner: : Steven J. Bos  
Docket No. : 55320.000402  
Customer No. : 21967

**MAIL STOP AMENDMENT**Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450**SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT**

Sir:

In accordance with 37 C.F.R. §§ 1.97 and 1.98, and in compliance with the duty of disclosure set forth in 37 C.F.R. § 1.56, Applicants submit attached Form PTO-SB/08B (modified) for consideration and request the references cited therein be made of record by the U.S. Patent and Trademark Office in the above-captioned application.

Applicants respectfully point out that the submission of the listed references in this Information Disclosure Statement is not an admission that they are prior art or that they are material to the patentability of any claims of the application. Also, the submission of this Information Disclosure Statement is not an indication that a search has been made by the Applicants.

For the convenience of the Examiner in considering the cited references, a copy of each of the cited references is enclosed with this communication. In considering the cited

ALL REFERENCES CONSIDERED EXCEPT WHERE LINED THROUGH. /S.H./

PATENT APPLICATION NO.: 10/519,142  
ATTORNEY DOCKET: 55320.000401

references, it may be noted by the Examiner that certain of the references may contain markings, underlinings, and/or other notations. These markings, underlinings, and/or other notations are not to be construed as drawing the Examiner's attention either to selected parts or away from other parts of the cited references. Any such markings were either present on the copies of the cited references obtained by the associated individuals, or were made thereon during the study of the references by the associated individuals.


Consideration of the foregoing plus the prompt return of a copy of the enclosed Form SB/08B with the Examiner's initials in the left column in accordance with MPEP 609 are respectfully requested.

In accordance with 37 C.F.R. § 1.97(b), this Information Disclosure Statement is believed to be submitted prior to issuance of a first Office Action. Therefore, it is respectfully submitted that no fee is required for consideration of this information. However, in the event any fee is deemed necessary, the Commissioner is authorized to charge the undersigned's Deposit Account No. 50-0206.

Respectfully submitted,

HUNTON & WILLIAMS LLP

Dated: May 14, 2007

By:   
Dwight M. Benner, II  
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Substitute for Form 1449/PTO

**INFORMATION DISCLOSURE  
STATEMENT BY APPLICANT**

(use as many sheets as necessary)

<b>Application Number</b>	<b>10/584,301</b>
<b>Filing Date</b>	<b>June 23, 2006</b>
<b>First Named Inventor</b>	<b>Henrik JENSEN, et al.</b>
<b>Art Unit</b>	<b>1615</b>
<b>Examiner Name</b>	<b>Steven J. Bos</b>
<b>Attorney Docket Number</b>	<b>55320.000402</b>

Sheet 1 of 1

**OTHER DOCUMENTS - NON-PATENT LITERATURE DOCUMENTS**

Examiner Initials	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published	TRANSLATION	
			YES	NO
	1.	Written Opinion issued in International Application No. PCT/DK03/00439, dated July 28, 2004.	<input type="checkbox"/>	<input type="checkbox"/>
	2.	Standard Search Report in DK2002 00975, dated February 5, 2003.	<input type="checkbox"/>	<input type="checkbox"/>
	3.	International Search Report in PCT/DK03/00439, dated July 14, 2004.	<input type="checkbox"/>	<input type="checkbox"/>
	4.	International Search Report in PCT/DK03/00934, dated January 18, 2005.	<input type="checkbox"/>	<input type="checkbox"/>
	5.	Schaumburg, Kjeld, "Supercritical Solvents for Preparation of Nanoparticles, sustainable technologies for the synthesis and compounding of functional nanoparticles", University of Copenhagen	<input type="checkbox"/>	<input type="checkbox"/>
	6.	www.kemira.com/pigments, Kemira, Product Data sheet, Kemira An and Preliminary Data Sheet for AXX	<input type="checkbox"/>	<input type="checkbox"/>
	7.	www.kemira.com/pigments/titanium_in_brief/titanium.html, "Titanium and titanium dioxide in brief", Sulphate process; Chloride process; Main technical properties of TiO2 pigments	<input type="checkbox"/>	<input type="checkbox"/>
	8.	www.toto.co.jp/hydro_e/hydro_el.htm, "Super-hydrophilic photocatalyst and its applications", TOTO Ltd., Photocatalyst Business Division (7 pages)	<input type="checkbox"/>	<input type="checkbox"/>
	9.	www.bikek.com.tw/titanium.htm, "BikTek Bicycle Industrial Know How & Technology", Titanium Technical Services. Web Site.	<input type="checkbox"/>	<input type="checkbox"/>
	10.	Kalaji, M., www.chemsoc.org, "Fifth International Conference on Materials Chemistry, Photoactive TiO2 nanostructured colloidal particles and thin films prepared by surfactant templating", chemsoc, Department of Chemistry, University of Wales Bangor, UK	<input type="checkbox"/>	<input type="checkbox"/>
	11.	www.businessinvestor.com, Altair Nanotechnologies, Inc.	<input type="checkbox"/>	<input type="checkbox"/>
	12.	Kemira, Reflections, Customer Newsletter 2-2001	<input type="checkbox"/>	<input type="checkbox"/>

EXAMINER SIGNATURE /Sheng Han/

DATE CONSIDERED 05/06/2009

\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.